

# Recent progress in organic semiconductor polymer blend films for OFETs

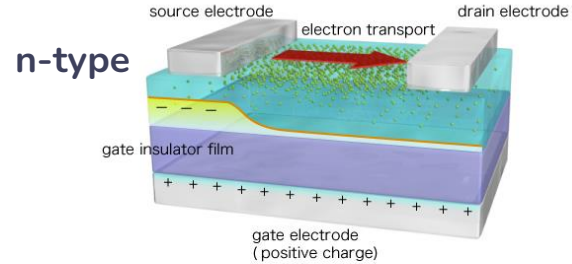
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**Elisabetta Colantoni**

Ph.D. Student, Department of Mathematics and Physics – Roma Tre University

Phose2023 - Workshop on "Photodetectors and sensors for particle identification and new physics searches"

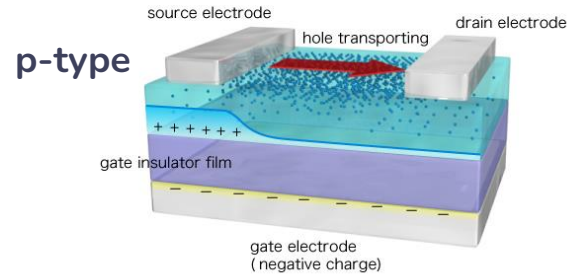
# OUTLINE

- ★ Organic Field-Effect Transistors (OFETs)
- ★ State of Art
- ★ Materials and methods
- ★ Optical Microscopy
- ★ ToF-SIMS Study
- ★ Electrical Characterization
- ★ X-Ray Characterization

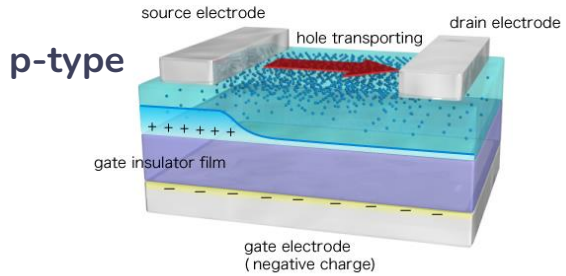
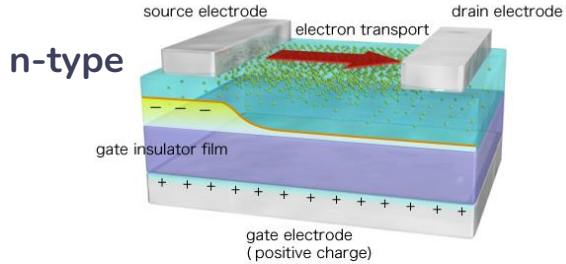


## Organic Semiconductor

- ★ Cheapness
- ★ Eco-sustainability
- ★ Bio-compatibility
- ★ Flexibility



Schematic representation of organic field-effect transistors.

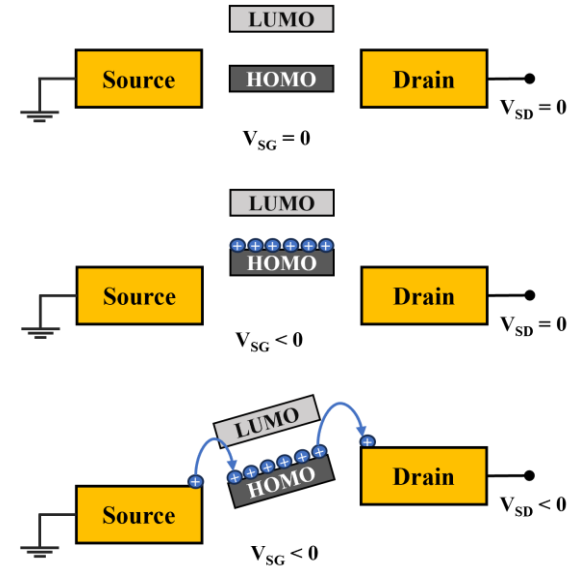


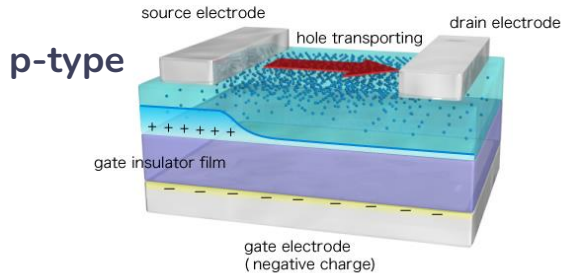
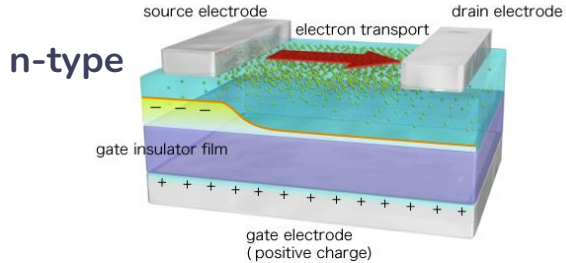
Schematic representation of organic field-effect transistors.

## Organic Semiconductor

- ★ Cheapness
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- ★ Flexibility

## Working Principle





Schematic representation of organic field-effect transistors.

## Organic Semiconductor

- ★ Cheapness
- ★ Eco-sustainability
- ★ Bio-compatibility
- ★ Flexibility

## Open issues

- ★ Low mobility
- ★ Shorter lifetime

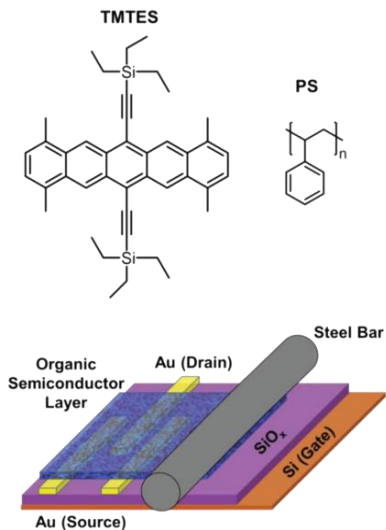
## GOAL

The study focuses on developing organic semiconductor/polymer blend films aimed at enhancing stability, mobility, and X-ray sensitivity.

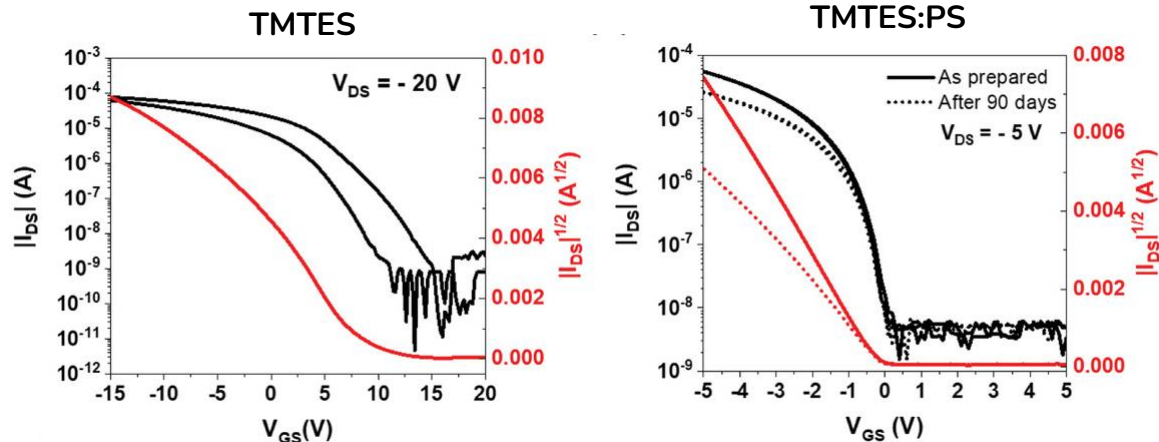


**A new generation of biocompatible devices (e.g., X-Ray Imaging system).**

## Device Fabrication

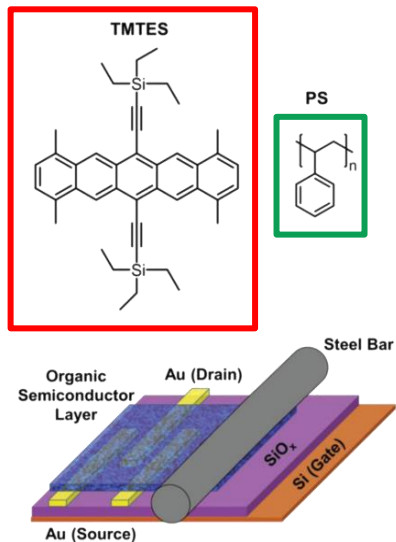


## Electrical Characterization

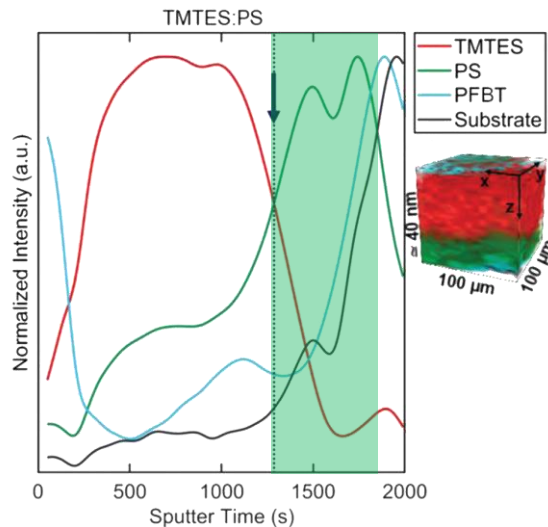


Sample	Mobility ( $cm^2V^{-1}s^{-1}$ )	V <sub>th</sub> (V)
TMTES	$(1.0 \pm 0.3) \cdot 10^{-1}$	$27 \pm 9$
TMTES:PS	$2.6 \pm 0.6$	$-(1.1 \pm 0.2)$

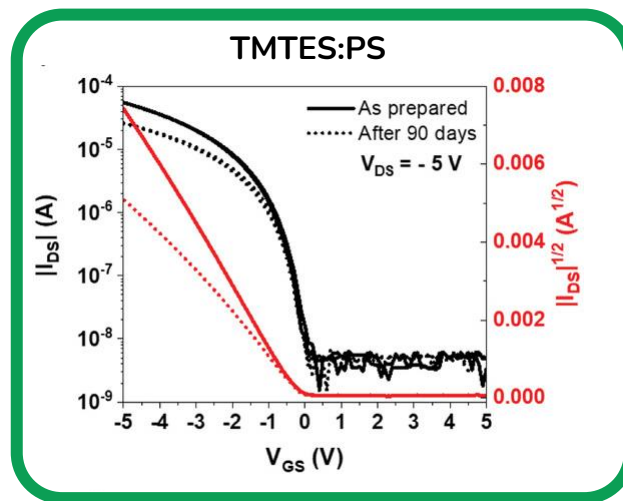
## Device Fabrication



## Electrical Characterization

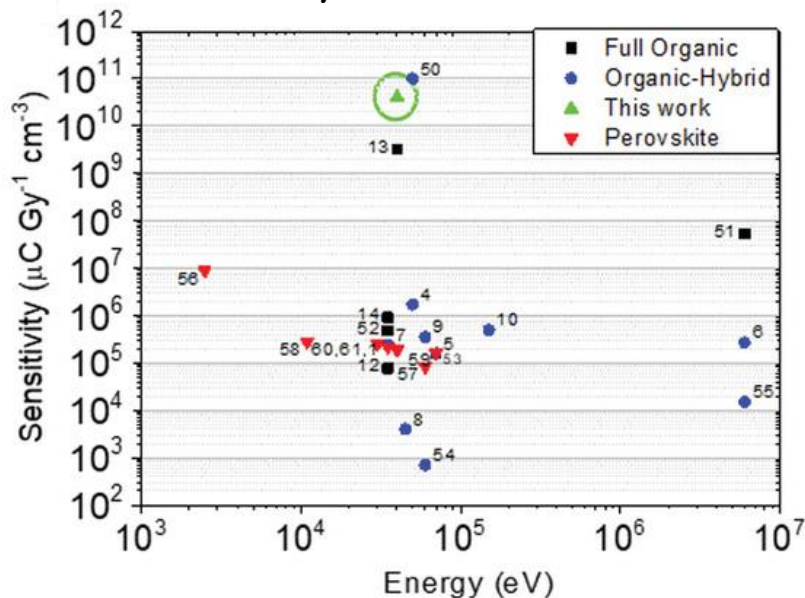


**PS Segregation**



Highest stability over time and OFET performance thanks to the bottom PS layer that passivates the interfacial charge traps.

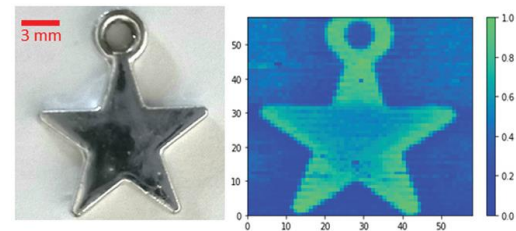
## X-Ray Characterization



High average mobility of  $2.6 \pm 0.6 \text{ cm}^2 \text{V}^{-1} \text{s}^{-1}$



Sensitivity to X-rays up to  $(4.10 \pm 0.05) 10^{10} \mu\text{C Gy}^{-1} \text{cm}^{-3}$ , highest value reported so far for a fully-organic tissue equivalent active layer



ELETTRA light source (Trieste, Italy).

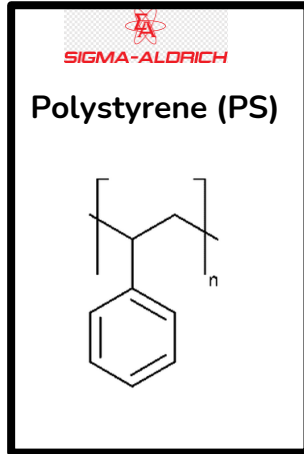
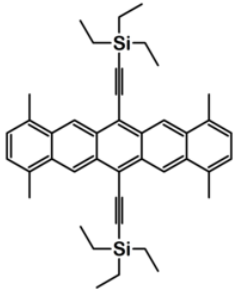
incident dose rate on the samples between 318 and 1665  $\mu\text{Gy s}^{-1}$

X-ray energy range (8.5–35 keV) and dose rates (0.05–35  $\text{mGy s}^{-1}$ ), well suited for diagnostic mammography



**Ossila**

TMTES-Pentacene



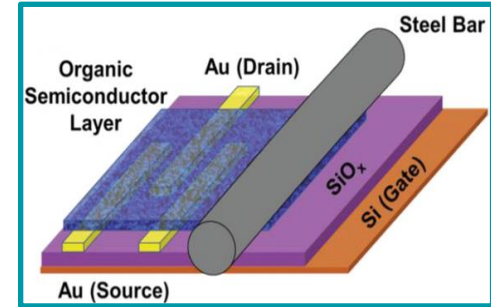
TMTES:PS volume ratio

1:0

4:1

2:1

1:2



## FABRICATION STEPS:

- ★ **Layout: Photolithography**
- ★ **Electrodes: Thermal Evaporation (5 nm Cr + 40 nm Au) and Lift-Off**
- ★ **Gold activation: UV Ozone 25 min + SAM of PFBT ( $10^{-3}$  M)**
- ★ **Deposition of active layer by BAMS: 10 mm/s, 105**

# Optical Microscopy

Rough surfaces

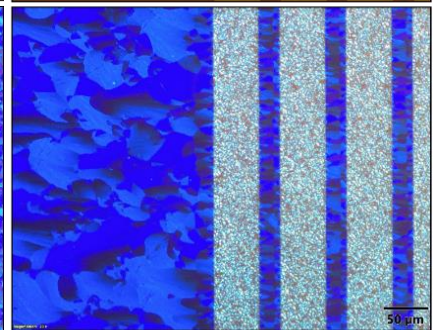
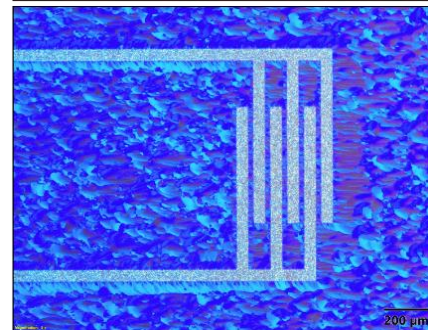
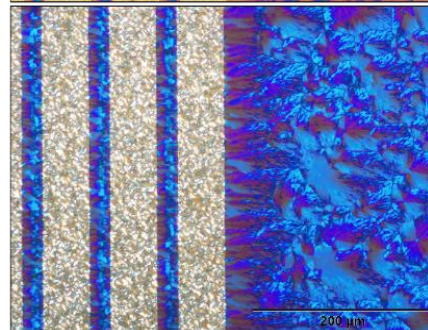
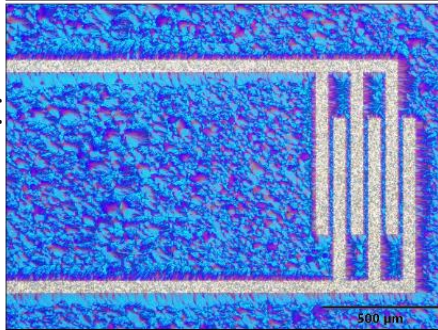
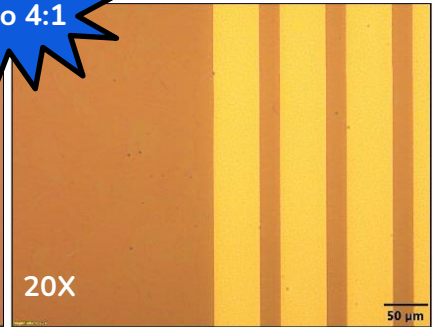
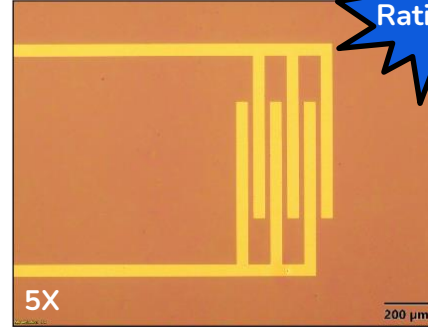
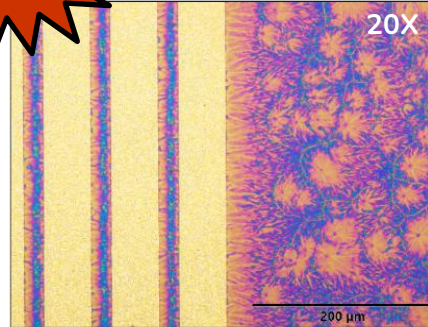
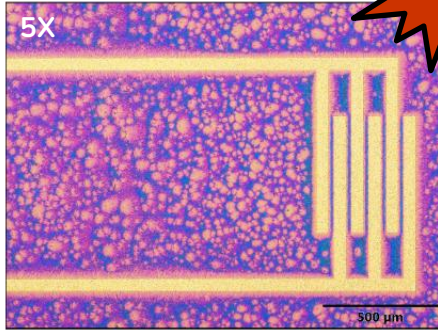
Ratio 1:0

Plate-like crystals, smoother surfaces

Ratio 4:1

Optical Microscopy

Polarized Optical Microscopy



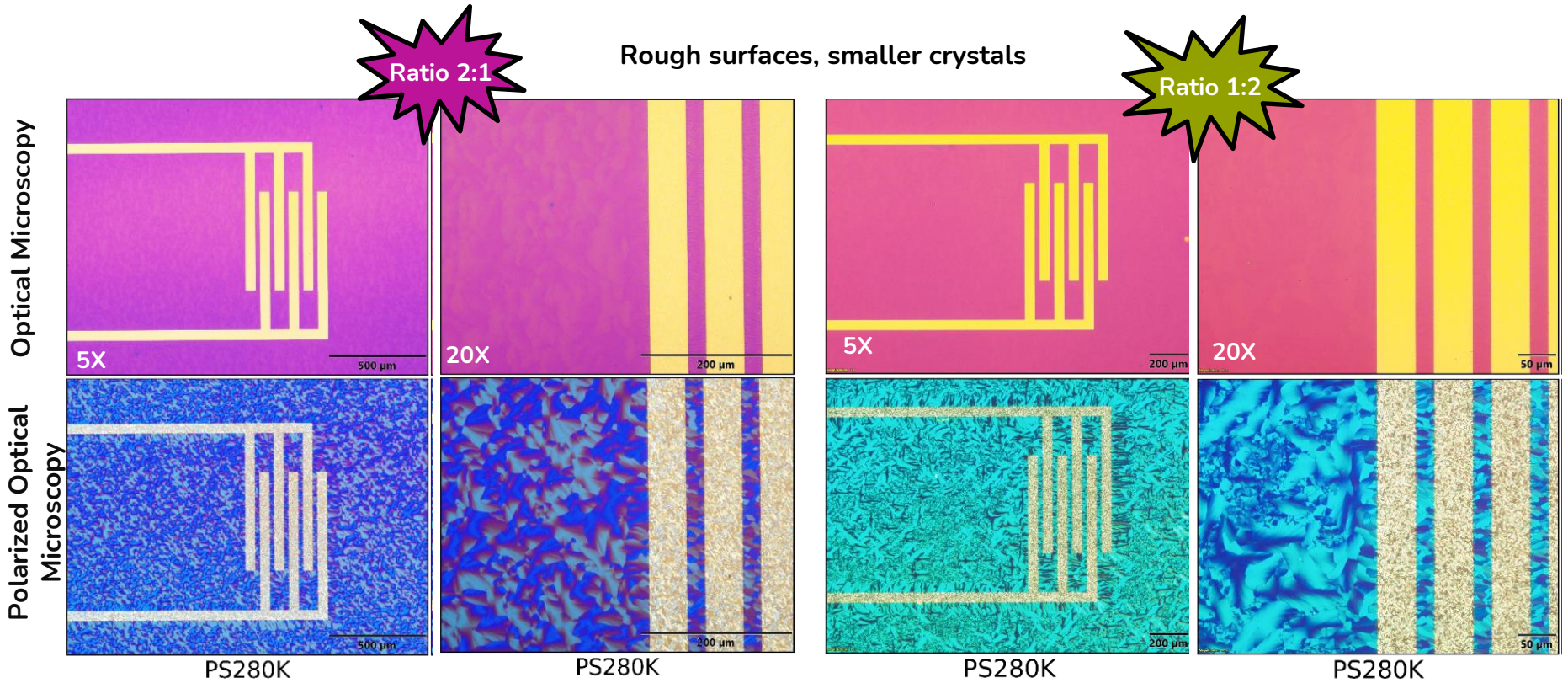
Pristine

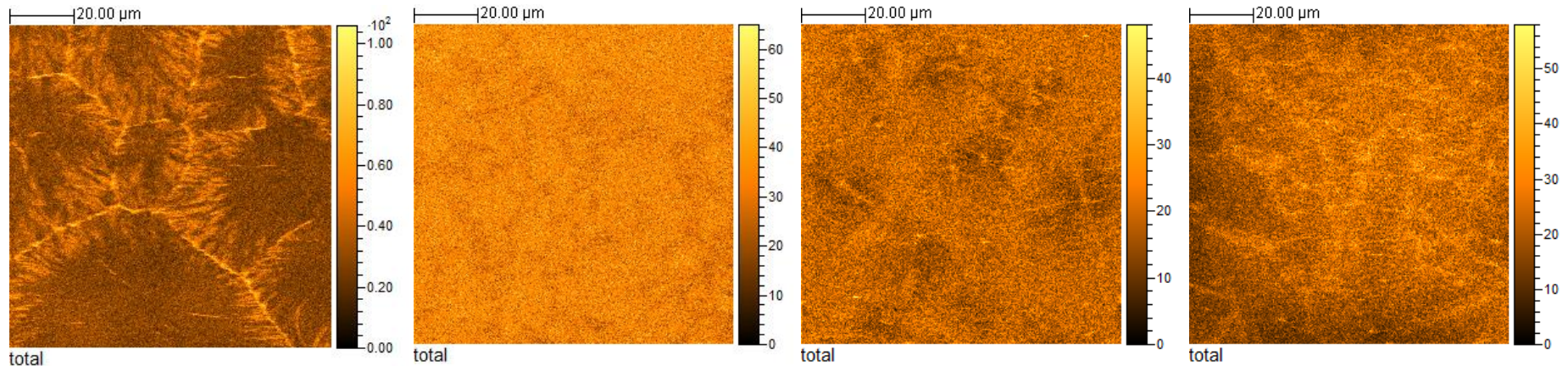
Pristine

PS280K

PS280K



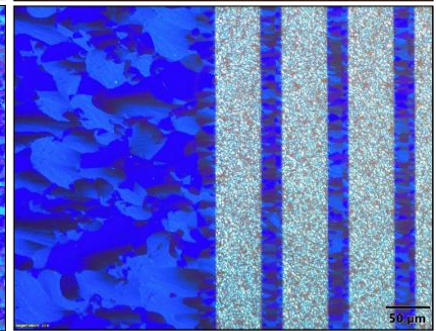
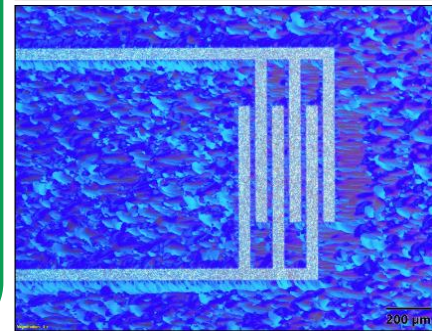
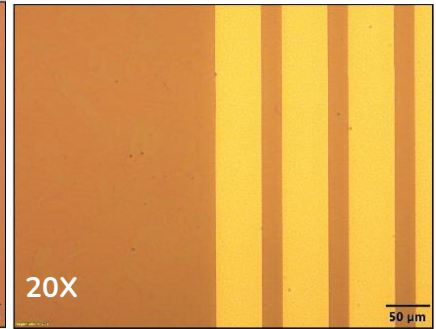
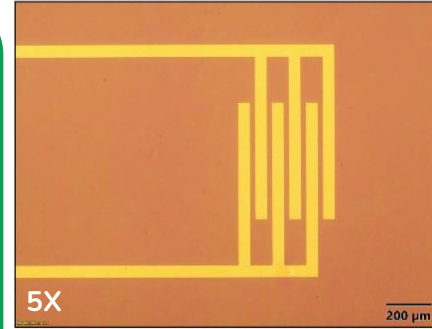
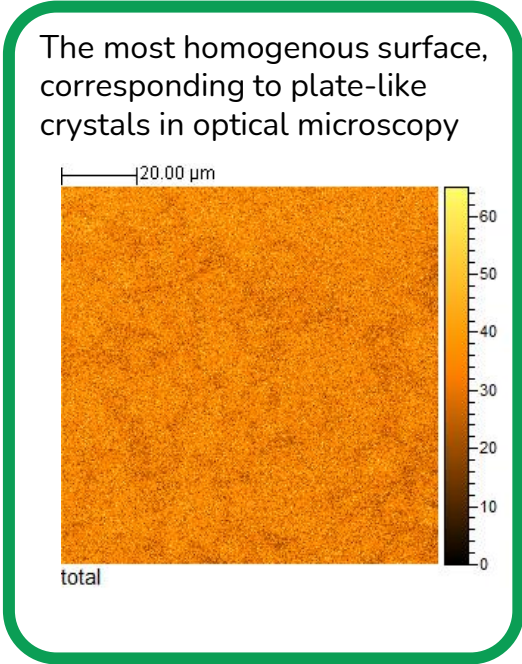




The superficial image of the total ion counts obtained from ToF-SIMS represents the spatial distribution of all detected ions, providing a comprehensive surface composition map of the sample at a microscopic level.



Ratio 4:1

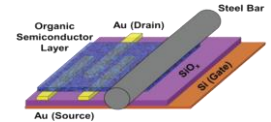
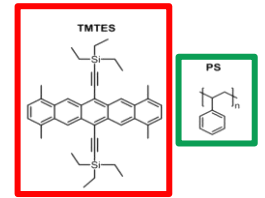


PS280K

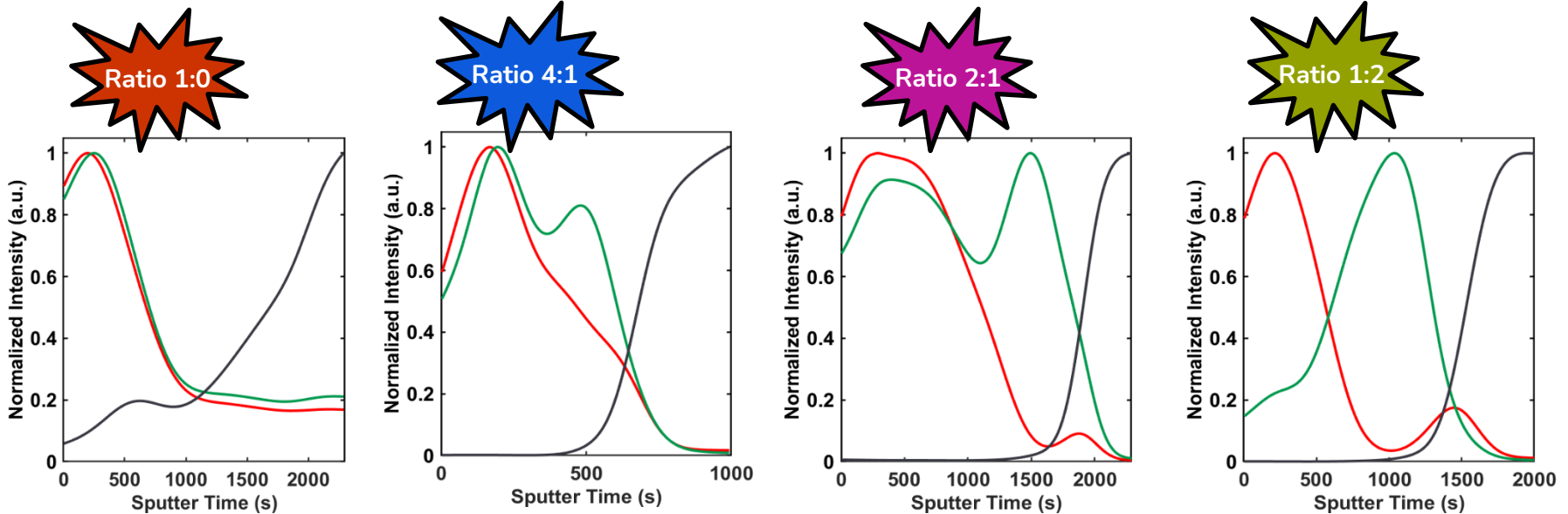
PS280K

# ToF-SIMS: Depth Profiling

- TMTES
- $\sum_{i=3}^7 C_iH_3$
- Substrate

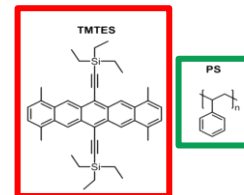


The depth profiling reveals the distribution of specific ions as a function of depth, offering insights into the layered structure and compositional variations within the sample

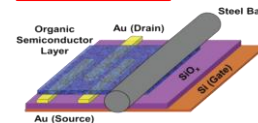


# ToF-SIMS: Depth Profiling

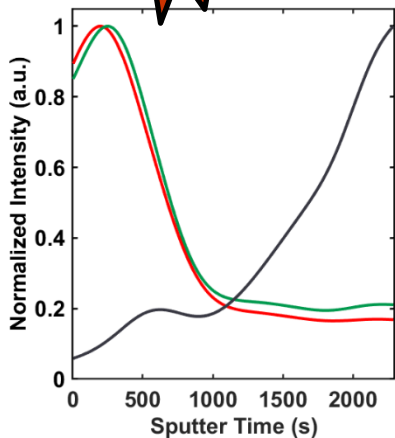
- TMTES
- $\sum_{i=3}^7 C_iH_3$
- Substrate



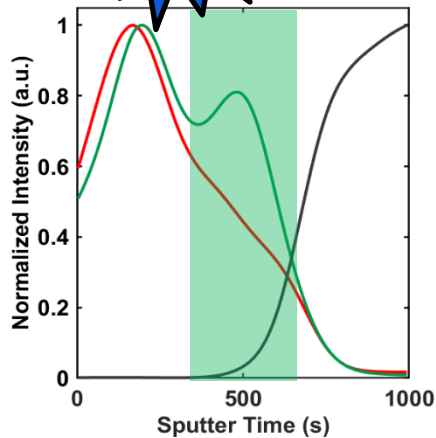
In all TMTES:PS devices there is a clear phase segregation



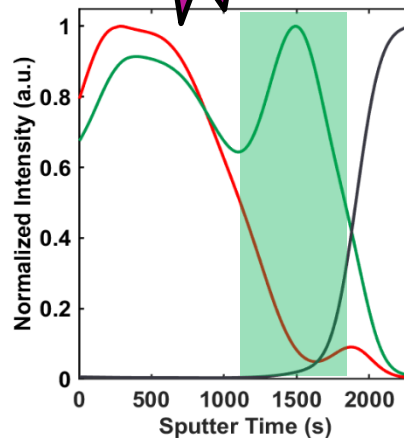
Ratio 1:0



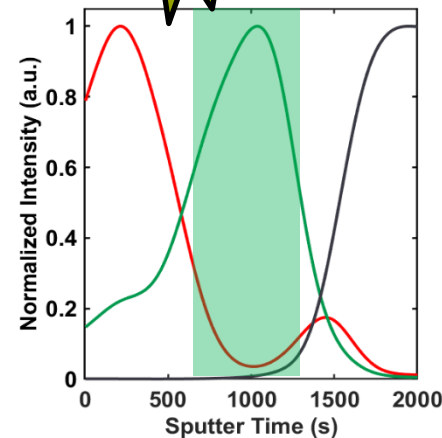
Ratio 4:1

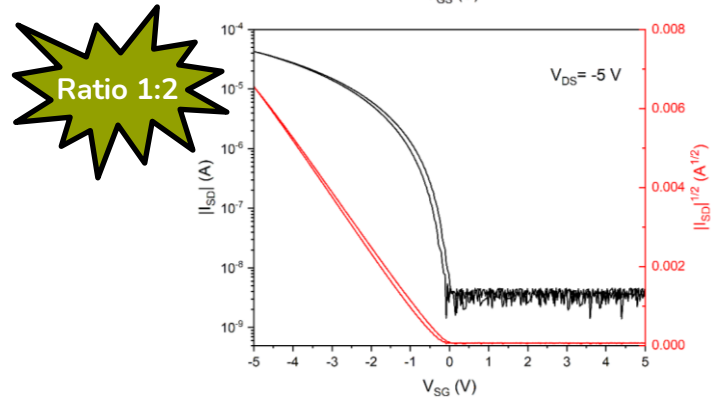
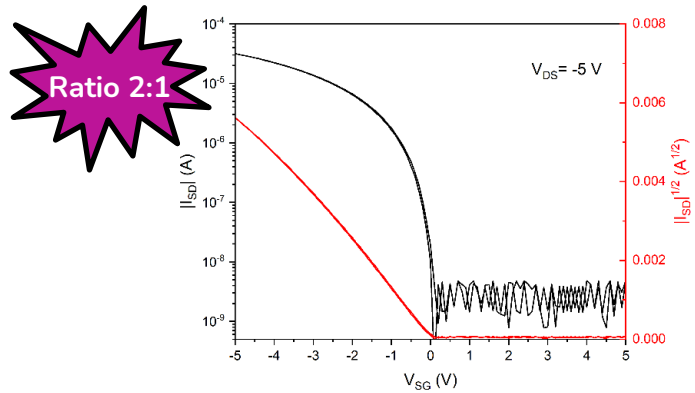
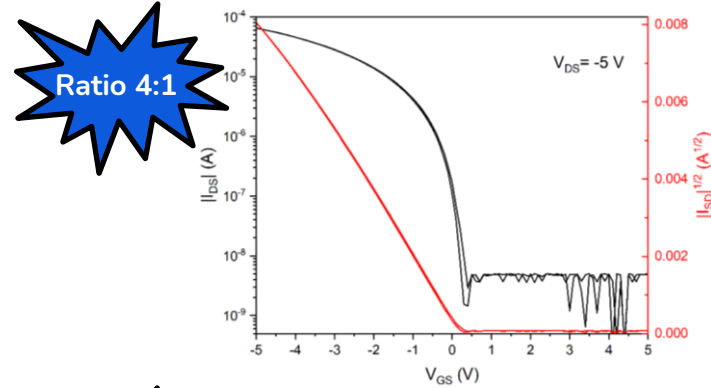
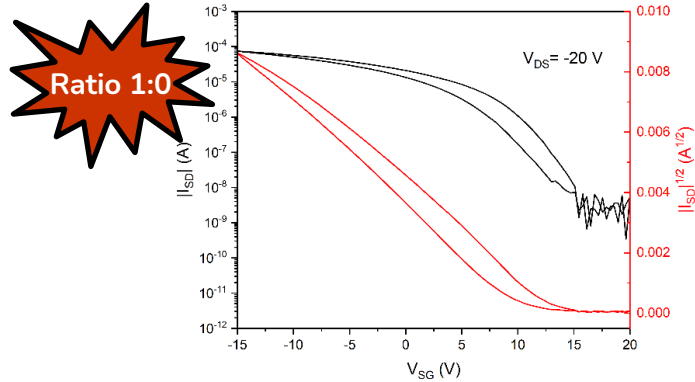


Ratio 2:1



Ratio 1:2





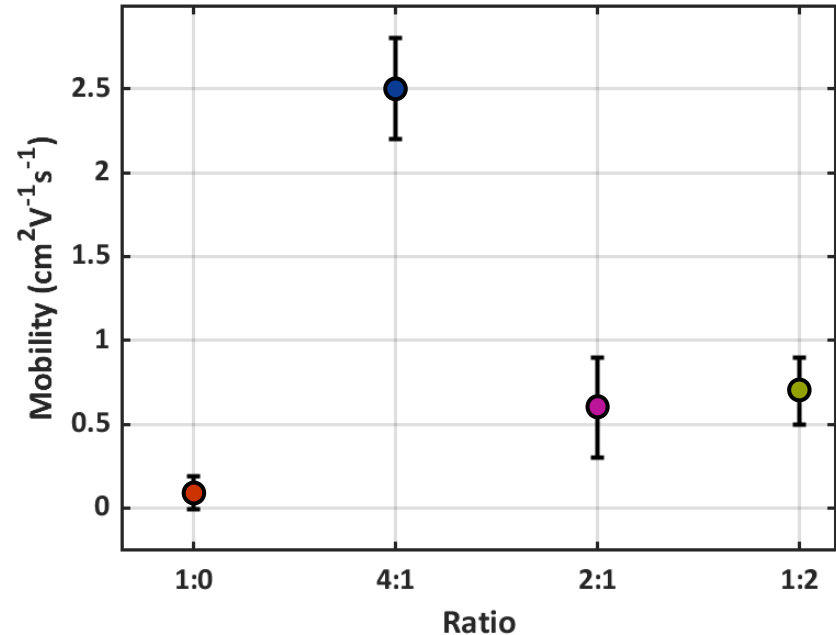


Ratio	Mobility ( $\text{cm}^2\text{V}^{-1}\text{s}^{-1}$ )	Vth (V)
1:0	$(0.90 \pm 0.05) \cdot 10^{-1}$	$15 \pm 3$
4:1	$2.5 \pm 0.3$	$0.4 \pm 0.1$
2:1	$0.6 \pm 0.3$	$0.1 \pm 0.06$
1:2	$0.7 \pm 0.2$	$0.2 \pm 0.06$

4:1 → Devices with the **highest mobility** correspond to:

- ★ The **plate-like crystals** in optical microscopy
- ★ Best **homogeneity** in Surface Analysis by ToF-SIMS

Ratio 4:1



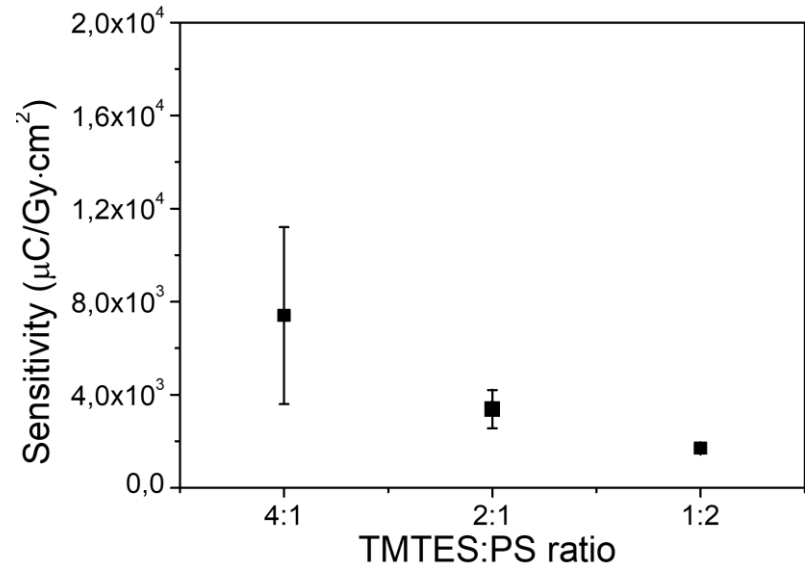
# X-Ray Characterization

X-ray tube with tungsten target was used at a fixed 40 kV operating voltage the filament current was changed between 100 and 500  $\mu\text{A}$  leading to an incident dose rate on the samples between 318 and 1665  $\mu\text{Gy s}^{-1}$

4:1  $\rightarrow$  Devices with the **highest sensitivity** correspond to:

- ★ The **plate-like crystals** in optical microscopy
- ★ Best **homogeneity** in Surface Analysis by ToF-SIMS
- ★ **Highest mobility**

Ratio 4:1



The study focuses on developing organic semiconductor/polymer blend films aimed at enhancing stability, mobility, and X-ray sensitivity, targeting applications in flexible and bio-electronic devices.

## Goals:

- ★ Improved OFET performance with TMTES-Pentacene:Polystyrene blends.
- ★ Investigation of phase segregation and its impact on device efficiency.
- ★ Determination of the optimal TMTES:PS ratio (**4:1**) for highest device performance.
- ★ Achievement of high sensitivity in X-ray characterization.

## To-Do list:

- ★ Evaluate devices with a lower amount of PS (e.g., ratio 8:1).
- ★ Assess long-term stability.
- ★ Perform AFM measurements to determine the roughness of the samples.



## Thanks to eMolMat Group

Prof. Marta Mas Torrent  
Dr. Carme Martinez Rodriguez  
Ph.D. Maria Elisabetta Giglio

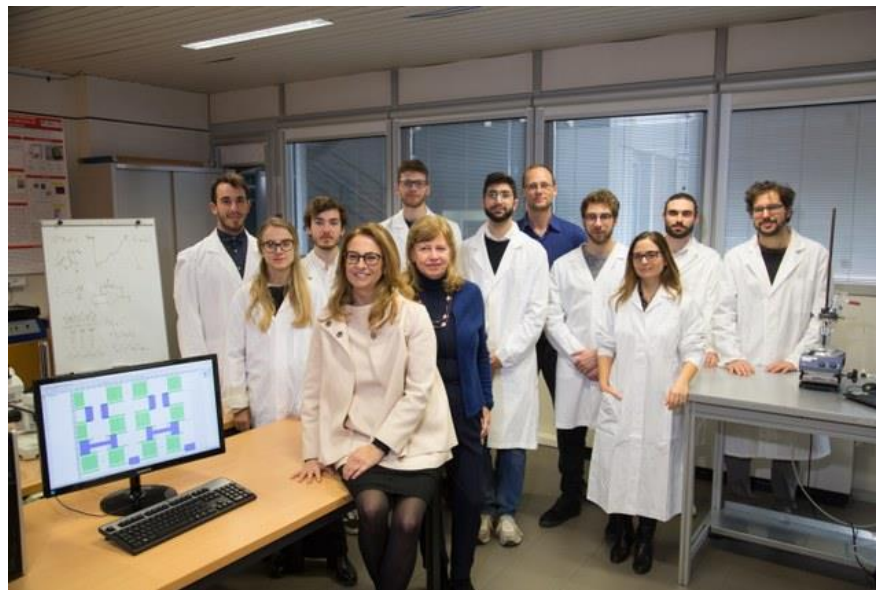


Dr. Beatrice Fraboni  
Dr. Laura Basiricò  
Dr. Ilaria Fratelli



ALMA MATER STUDIORUM  
UNIVERSITÀ DI BOLOGNA

## Thanks to Semiconductor Physics Group

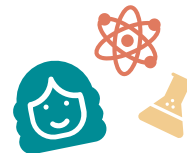




## Thanks to LASR3 Group

Dr. Paolo Branchini  
Dr. Luca Tortora  
Dr. Andrea Fabbri

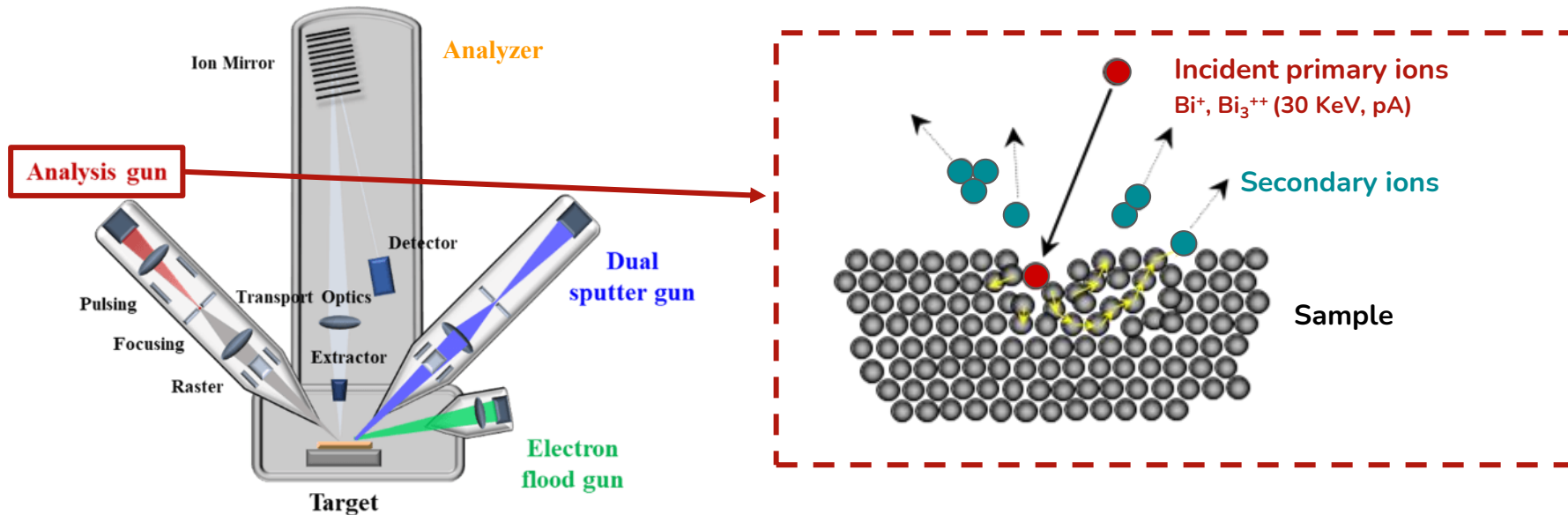
# Thanks for your kind attention!



# Backup slides

# ToF-SIMS principle

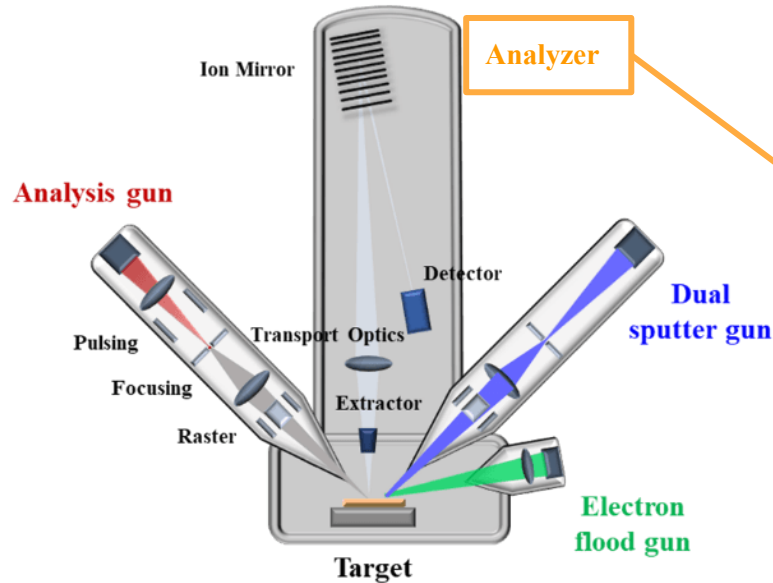
## IONTOF ToF-SIMS



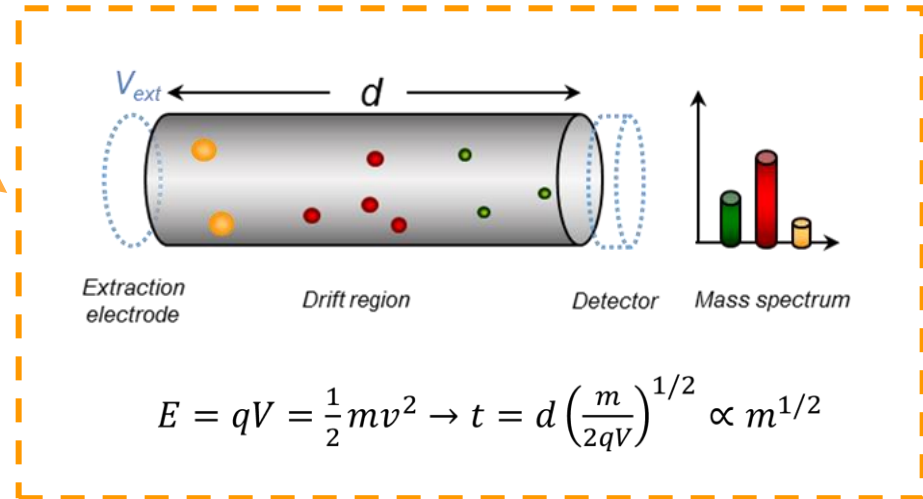


# ToF-SIMS principle

## IONTOF ToF-SIMS



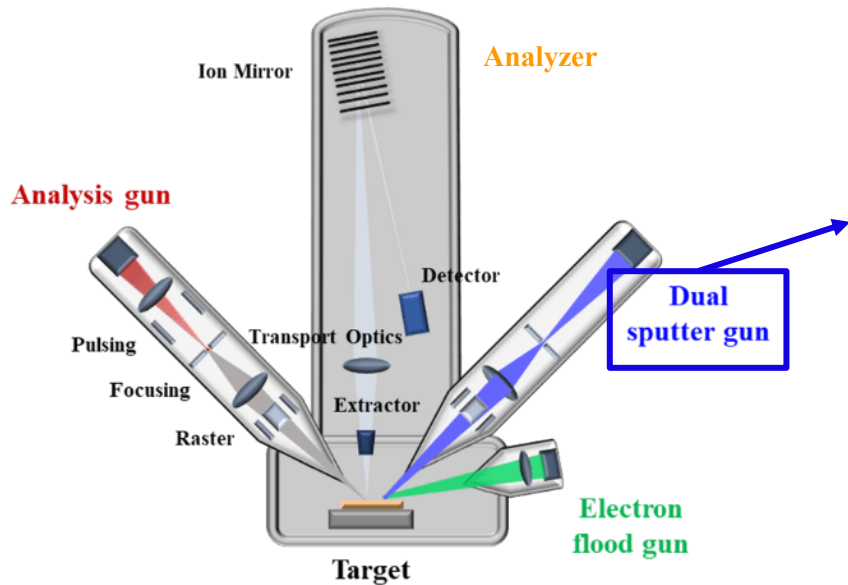
### Time-of-Flight detector



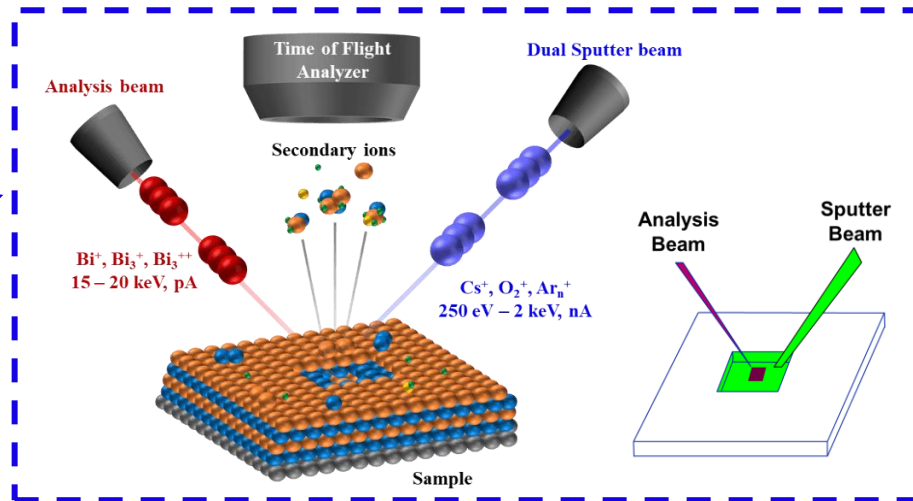


# ToF-SIMS principle

## IONTOF ToF-SIMS

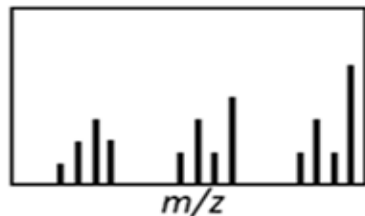


## Dual-beam mode

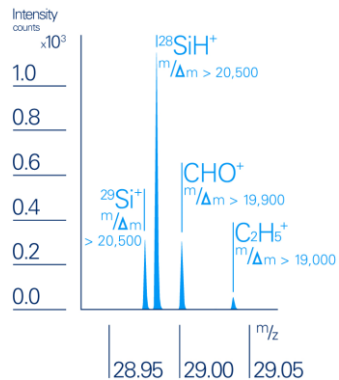


# ToF-SIMS data

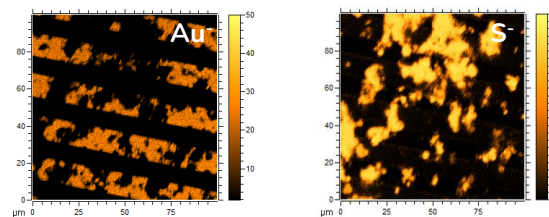
## Spectrometry



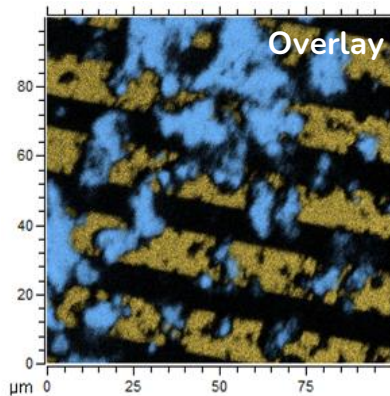
▲ High mass resolution  
(~20000 m/Δm)



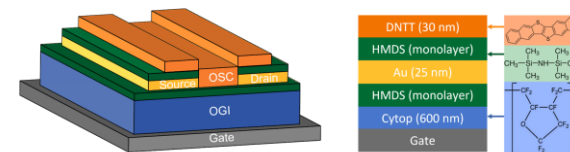
## Imaging



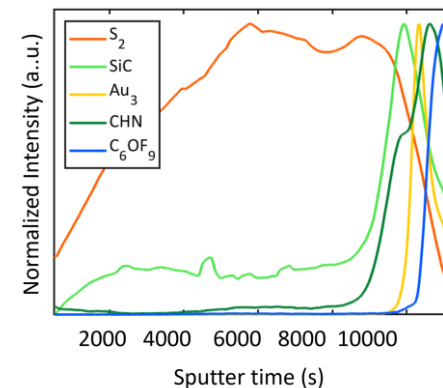
▲ High lateral resolution  
(~100 nm)



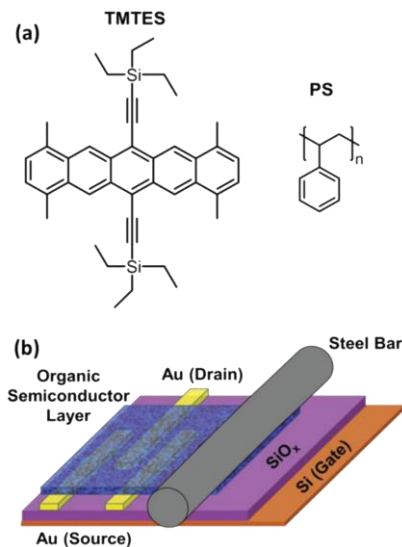
## Depth-Profiling



▲ Monolayer sensitivity  
(~5 nm)

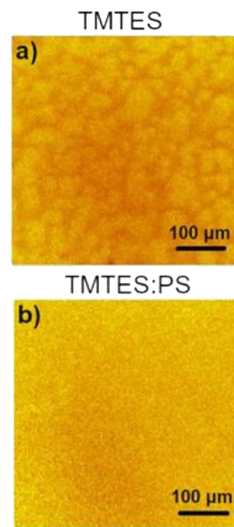


## Device Fabrication



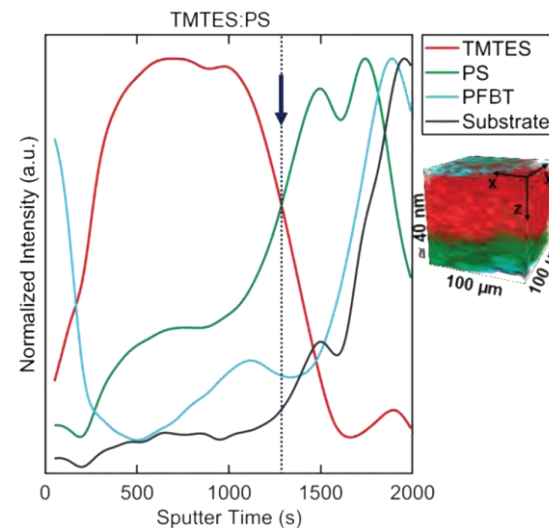
a) Chemical structures of TMTES and PS, and  
b) scheme of the OFET layout.

## Surface Analysis



ToF-SIMS 2D chemical maps: a) TMTES, and  
b) TMTES:PS sample.

## In-Depth Analysis



Normalized ToF-SIMS depth profiles and 3-D  
rendering of the characteristic ions.

Ratio 1:0

Ratio 2:1

Ratio 4:1

Ratio 1:2

